

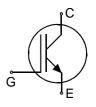
IGBT Chip in NPT-technology

Features:

- 1200V NPT technology
- positive temperature coefficient
- easy paralleling

This chip is used for:

- power module BUP 213
- **Applications:**
- drives



Chip Type	V _{CE}	<i>I</i> c	Die Size	Package
SIGC25T120C	1200V	15A	4.53 x 5.71 mm ²	sawn on foil

Mechanical Parameter

	-				
Raster size	4.53 x 5.71	mm ²			
Emitter pad size	2 x (2.18 x 1.6)				
Gate pad size	1.09 x 0.68				
Area total	25.9]			
Thickness	200	μm			
Wafer size	150	mm			
Max.possible chips per wafer	555				
Passivation frontside	Photoimide				
Pad metal	3200 nm AlSiCu				
Backside metal	Ni Ag –system suitable for epoxy and soft solder die bonding				
Die bond	Electrically conductive glue or solder				
Wire bond	Al, <500µm				
Reject ink dot size	Ø 0.65mm ; max 1.2mm				
Recommended storage environment	Store in original container, in dry nitrogen, in dark environment, < 6 month at an ambient temperature of 23°C				



Maximum Ratings								
Parameter	Symbol	Value	Unit					
Collector-Emitter voltage, T_{vj} =25 °C	V _{CE}	1200	V					
DC collector current, limited by $T_{vj max}$	I _C	1)	А					
Pulsed collector current, t_p limited by $T_{vj max}$	I _{c,puls}	45	А					
Gate emitter voltage	V _{GE}	±20	V					
Junction temperature range	T _{vj}	-55 +175	°C					
Operating junction temperature	T _{vj}	-55+150	°C					
Short circuit data ²⁾ V_{GE} = 15V, V_{CC} = 900V, T_{vj} = 150°C	t _{sc}	10	μs					
Reverse bias safe operating area ²⁾ (RBSOA)	I _{C,max}	= 30A, $V_{CE,max}$ = 1200 $T_{vj} \le 150^{\circ} C$	/					

¹⁾ depending on thermal properties of assembly

²) not subject to production test - verified by design/characterization

Static Characteristic (tested on wafer), T_{vj} =25 °C

Parameter	Symbol	Conditions	Value			Unit
	min. typ.		typ.	max.		
Collector-Emitter breakdown voltage	V _{(BR)CES}	V _{GE} =0V , <i>I</i> _C = 1mA	1200			
Collector-Emitter saturation voltage	V _{CEsat}	V _{GE} =15V, <i>I</i> _C =15A	2.0	2.5	3.0	V
Gate-Emitter threshold voltage	V _{GE(th)}	$I_{\rm C}$ =0.6mA , $V_{\rm GE}$ = $V_{\rm CE}$	4.5	5.5	6.5	
Zero gate voltage collector current	I _{CES}	V _{CE} =1200V , V _{GE} =0V			1.9	μA
Gate-Emitter leakage current	I _{GES}	$V_{CE}=0V$, $V_{GE}=20V$			480	nA
Integrated gate resistor	r _G			none		Ω

Dynamic Characteristic (not subject to production test - verified by design / characterization),

*T*_{vj} =25 °C

Parameter	Symbol	Conditions	Value			Unit
Falameter	Symbol	Conditions	min.	typ.	max.	Unit
Input capacitance	Cies	$V_{CE}=25V$,		1000		
Output capacitance	Coes	$V_{\rm GE}=0V$,		150		pF
Reverse transfer capacitance	Cres	f=1MHz		70		

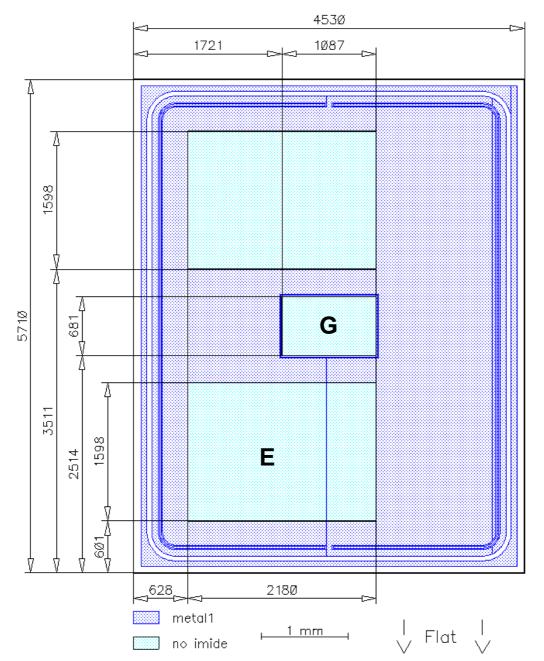


Further Electrical Characteristic

Switching characteristics and thermal properties are depending strongly on module design and mounting technology and can therefore not be specified for a bare die.



Chip Drawing



Die-Size 4530 um \times 5710 um

E = Emitter pad **G** = Gate pad



Description

AQL 0,65 for visual inspection according to failure catalogue

Electrostatic Discharge Sensitive Device according to MIL-STD 883

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